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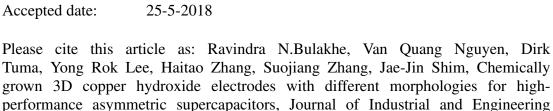
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### ACCEPTED MANUSCRIPT

# Chemically Grown 3D Copper Hydroxide Electrodes with Different Morphologies for High-Performance Asymmetric Supercapacitors

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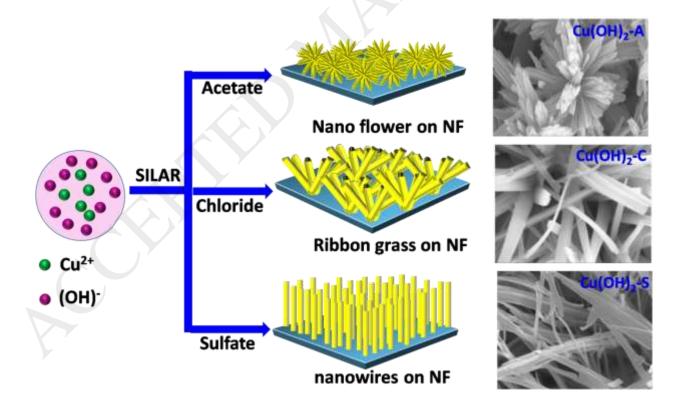
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## **Graphical abstract**



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